

<b>INFORMATION DISCLOSURE CITATION</b> PTO-1449		<b>CUSTOMER NUMBER</b>  25537		ATTORNEY'S DKT No. 03-1017		APPLICATION No. 107/20,868	
				APPLICANT(S) Christopher L. HELBLING et al.			
				FILING DATE November 24, 2003		GROUP 2614	
<b>U.S. PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
	US 6,788,772	09/2004	Barak et al.				
	US 6,882,714	04/2005	Mansfield				
	US 5,535,265	07/1996	Suwandhaputra				
	US 5,982,870	11/1999	Pershan et al.				
	US 2004/0264654	12/2004	Reding et al.				
	US 2005/0053221	03/2005	Reding et al.				
	US 7,315,614	01/2008	Bedingfield et al.				
	US 7,379,538	05/2008	Ali et al.				
	US 2003/0142798	07/2003	Gavette et al.				
	US 6,801,610	10/2004	Malik				
	US 6,798,753	09/2004	Doganata et al.				
	US 2003/0208541	11/2003	Musa				
	US 6,167,119	12/2000	Bartholomew et al.				
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	US 2004/0208305	10/2004	Gross et al.				
	US 6,731,238	09/2004	Johnson				
	US 6,442,748	08/2002	Bowman-Amuah				
	US 6,005,870	12/1999	Leung et al.				
<b>FOREIGN PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No
	JP 2000-134309	09/2000	Japan			X	
	JP 2002-300290	10/2002	Japan			X	
	JP 2002-16673	01/2002	Japan			X	
	JP 9-64869	03/1997	Japan			X	
	JP 2001-144859	05/2001	Japan			X	
	EP 1 193 617	04/2002	Europe				
	JP 9-64977	03/1997	Japan			X	
	JP 11-55407	02/1999	Japan			X	
	JP 10-336319	12/1998	Japan			X	
<b>OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)</b>							
EXAMINER				DATE CONSIDERED			

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